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PATENT APPLICATION

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Naomasa SHIRAISHI

Application No.: 09/868,316

Docket No.: 109820

Filed: August 23, 2001

For: PRODUCING METHOD AND APPARATUS OF PHOTOMASK

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Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

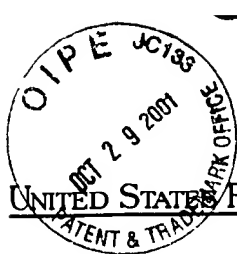
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Date: October 29, 2001

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APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
09/868,316	08/23/2001	1756	1230	109820	4	15	6

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CONFIRMATION NO. 8919

FILING RECEIPT



OC00000006872874

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Applicant(s)

Naomasa Shiraishi, Saitama-Shi, JAPAN;

Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP99/06962 12/10/1999

Foreign Applications

JAPAN 10/360594 12/18/1998

Projected Publication Date: Not Applicable, filed prior to November 29, 2000

Non-Publication Request: No

Early Publication Request: No

Title

~~Photo mask production method and apparatus~~

Producing method and apparatus
of photomask

Preliminary Class

430

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